

半导体物理

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第九章 金半接触

9.1 金半接触的能带图

9.2 金半接触的整流输运理论

9.3 少子注入和欧姆接触

9.1 金半接触的能带图₁

9.1.1 功函数和电子亲和能

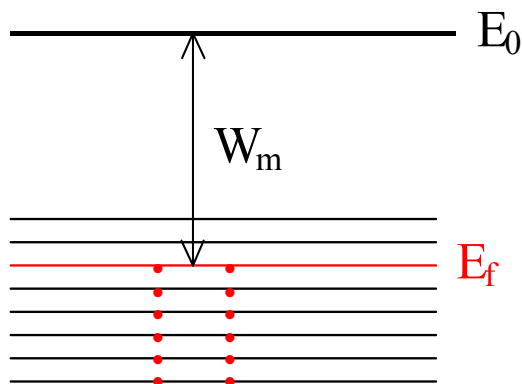
功函数: $W = E_0 - E_f$

—真空能级与费米能级之差

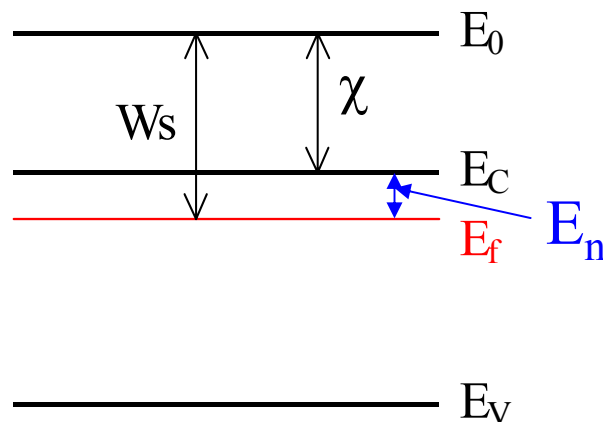
电子亲和能 χ : 真空能级与导带底之差

真空能级 E_0 :

真空中静止电子的能量



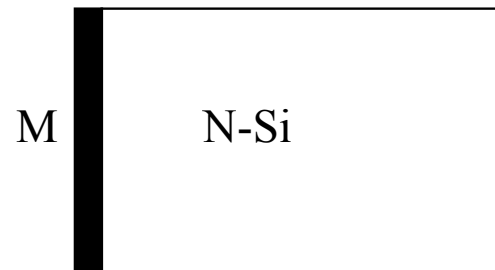
$$W_m = E_0 - E_F$$



$$W_s = E_0 - E_F$$

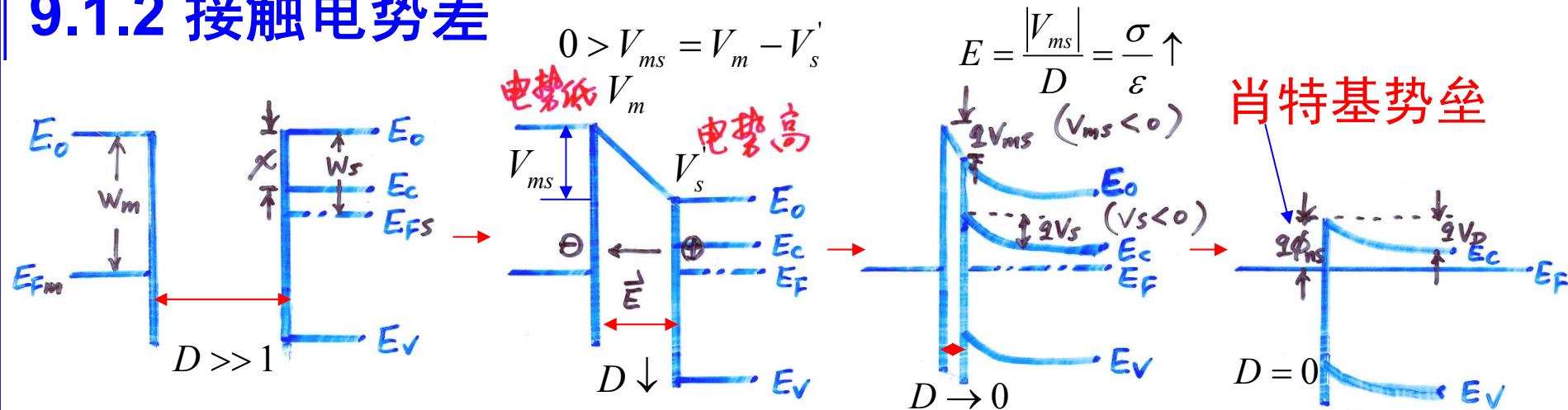
$$\chi = E_0 - E_C$$

$$E_n = E_c - E_f$$



9.1 金半接触的能带图₂

9.1.2 接触电势差



$$(W_m > W_s)$$

$$qV_{ms} = W_s - W_m$$

$$qV_{ms} + qV_s = W_s - W_m$$

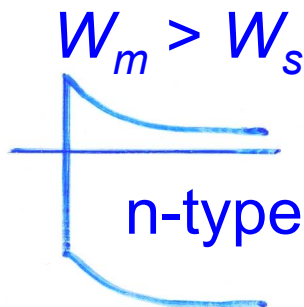
$$q\phi_{ns} = W_m - \chi$$

$$qV_D = W_m - W_s$$

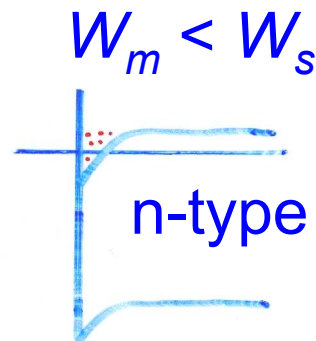
接触电势差 $V_{ms} = V_m - V'_s$ 表面势：半导体表面和体内的电势差

阻挡层：
高阻，整流

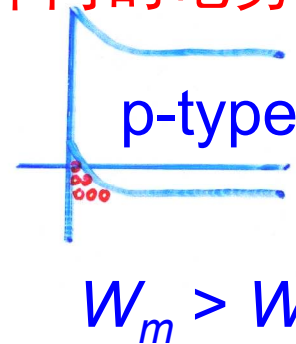
反阻挡层：
低阻，欧姆



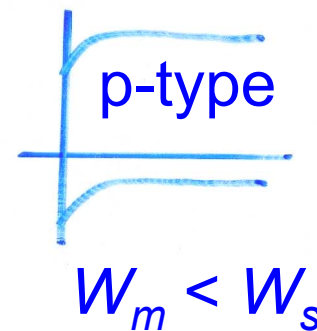
整流



欧姆



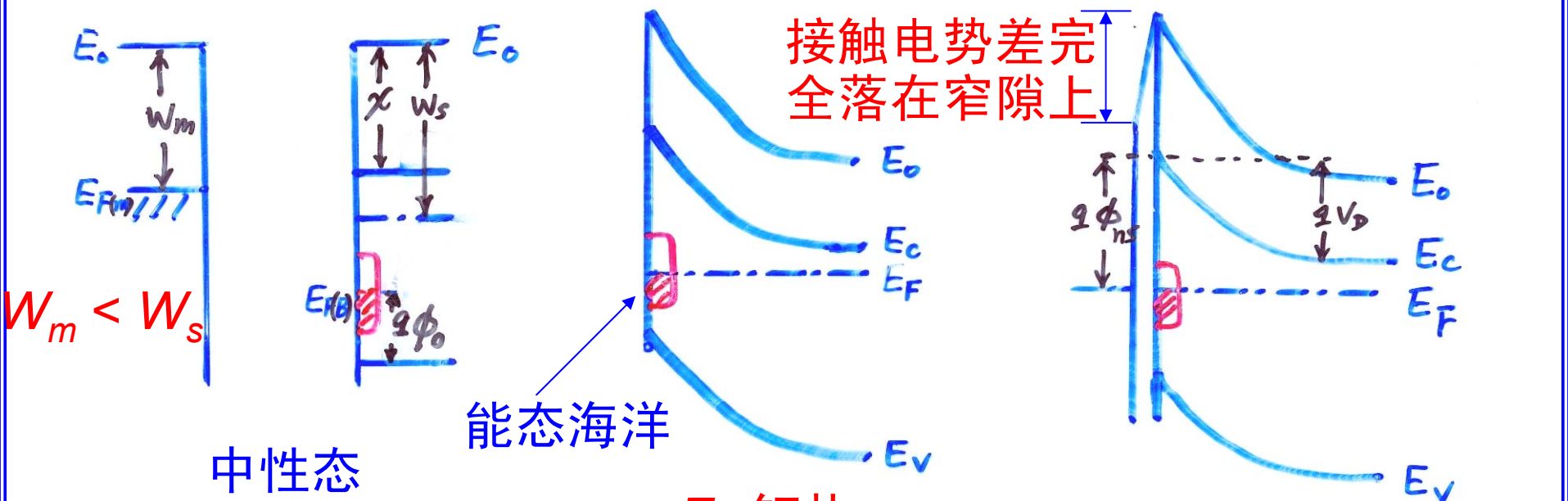
欧姆



整流

9.1 金半接触的能带图₃

9.1.3 表面态对接触势垒的影响



接触电势差完全落在窄隙上

E_F 钉扎

E_F 钉扎效应

$$\left\{ \begin{array}{l} q\phi_{ns} \approx \frac{2}{3}E_g \\ qV_D \approx \frac{2}{3}E_g - (E_C - E_F) \end{array} \right.$$

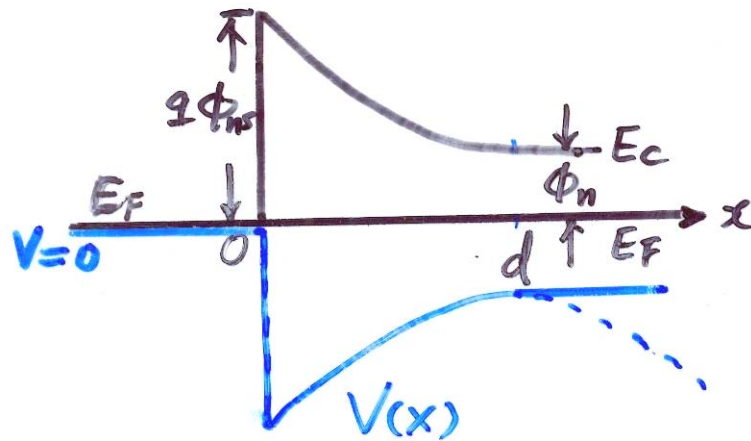
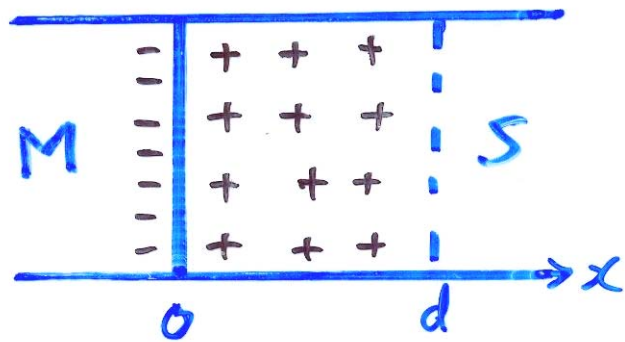
1° 势垒高度与金属功函数基本无关

2° 即使 $W_m < W_s$ ，阻挡层依然存在

9.1 金半接触的能带图₄

9.1.4 势垒区的电势分布

—n型半导体



泊松方程

$$\frac{d^2V}{dx^2} = \begin{cases} -\frac{qN_D}{\epsilon_0\epsilon_r} & 0 \leq x \leq d \\ 0 & x > d \end{cases}$$

$$E(x) = -\frac{dV}{dx} = \frac{qN_D}{\epsilon_0\epsilon_r}(x-d) \quad \leftarrow E(d) = 0$$

$$V(x) = -\frac{qN_D}{2\epsilon_0\epsilon_r}(x^2 - 2xd) - \phi_{ns} \quad \leftarrow V(0) = -\phi_{ns}$$

$$\leftarrow V(d) = -\phi_n \quad \phi_{ns} = \phi_n + V_D$$

$$d = \left[\frac{2\epsilon_0\epsilon_r}{qN_D}(\phi_{ns} - \phi_n) \right]^{1/2} = \left(\frac{2\epsilon_0\epsilon_r}{qN_D} V_D \right)^{1/2}$$

9.1 金半接触的能带图⁵

9.1.5 肖特基接触的势垒电容

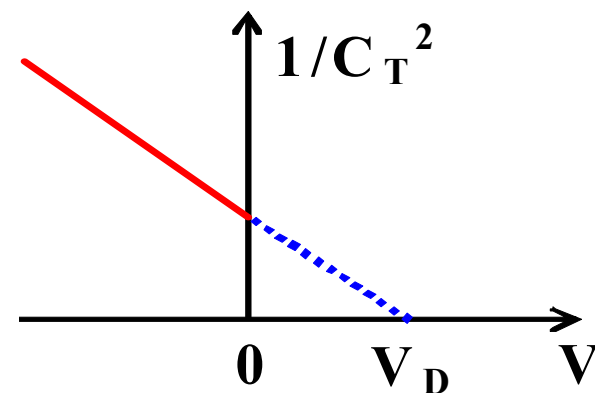
$$d = \left[\frac{2\varepsilon_0\varepsilon_r}{qN_D} (\phi_{ns} - \phi_n) \right]^{1/2} = \left(\frac{2\varepsilon_0\varepsilon_r}{qN_D} V_D \right)^{1/2}$$

施加反向偏压V时

$$d = \left[\frac{2\varepsilon_0\varepsilon_r}{qN_D} (V_D - V) \right]^{1/2}$$

平行板电容

$$C_T = A \frac{\varepsilon_0\varepsilon_r}{d} = A \left[\frac{\varepsilon_0\varepsilon_r q N_D}{2(V_D - V)} \right]^{1/2}$$



与单边突变p-n结相同

第九章 金半接触

9.1 金半接触的能带图

9.2 金半接触的整流输运理论

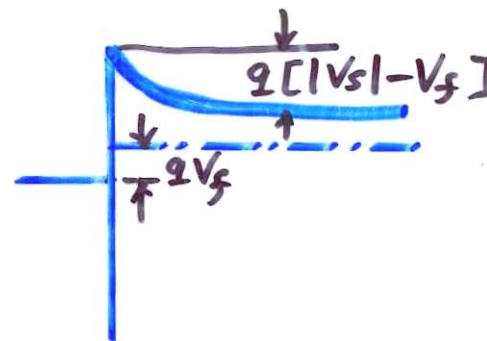
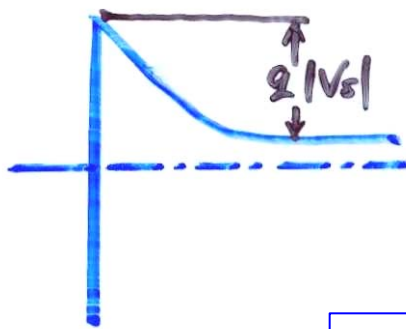
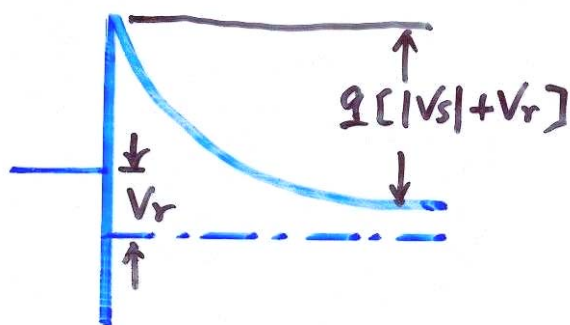
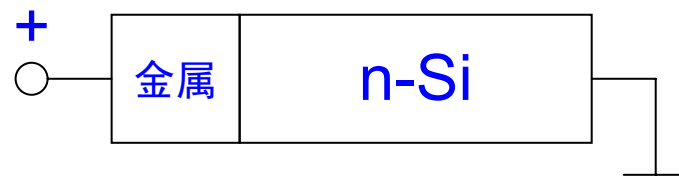
9.3 少子注入和欧姆接触

9.2 金半接触的整流输运理论₁

9.2.1 扩散理论

—适用于势垒宽度 \gg
电子平均自由程

$$l_n \ll d$$



同时考虑势垒区扩散和漂移电流

$$\mu = \frac{q}{kT} D$$

$$J = qn(x)\mu_n E(x) + qD_n \frac{dn(x)}{dx} = qD_n \left[-\frac{qn(x)}{kT} \frac{dV(x)}{dx} + \frac{dn(x)}{dx} \right]$$

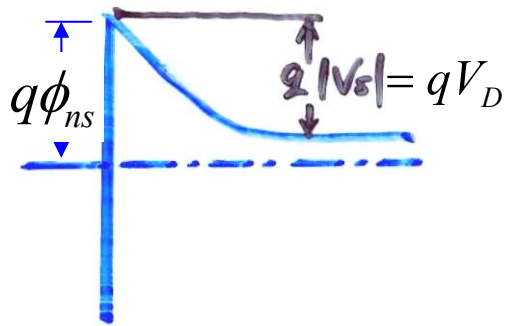
$$E(x) = -\frac{dV}{dx}$$

$$J \exp\left[-\frac{qV(x)}{kT}\right] = qD_n \frac{d}{dx} \left\{ n(x) \exp\left[-\frac{qV(x)}{kT}\right] \right\}$$

9.2 金半接触的整流输运理论₂

9.2.1 扩散理论

积分 $\int_0^d dx \rightarrow J \exp\left[-\frac{qV(x)}{kT}\right] = qD_n \frac{d}{dx} \left\{ n(x) \exp\left[-\frac{qV(x)}{kT}\right] \right\}$



$$\int_0^d J \exp\left[-\frac{qV(x)}{kT}\right] dx \leftarrow V(x) = -\frac{qN_D}{2\varepsilon_0\varepsilon_r}(x^2 - 2xd) - \phi_{ns}$$

$$= J \int_0^d \exp\left\{ \frac{q}{kT} \left[\frac{qN_D}{2\varepsilon_0\varepsilon_r}(x^2 - 2xd) + \phi_{ns} \right] \right\} dx \leftarrow x^2 \ll 2xd \quad \exp\left[-\frac{qV(x)}{kT}\right]$$

$$\approx J \int_0^d \exp\left(\frac{q\phi_{ns}}{kT}\right) \exp\left(-\frac{q^2 N_D d}{\varepsilon_0 \varepsilon_r kT} x\right) dx$$

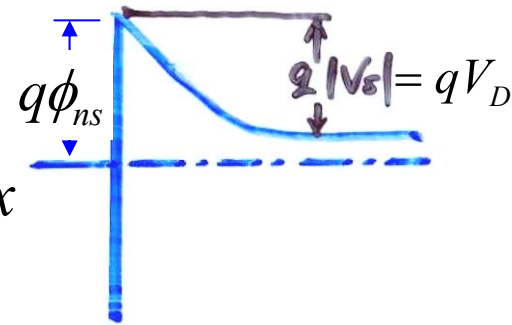
主要取决于
x=0附近的
电势值

$$= J \exp\left(\frac{q\phi_{ns}}{kT}\right) \frac{\varepsilon_0 \varepsilon_r kT}{q^2 N_D d} \left[1 - \exp\left(-\frac{q^2 N_D d^2}{\varepsilon_0 \varepsilon_r kT}\right) \right] \approx J \exp\left(\frac{q\phi_{ns}}{kT}\right) \frac{\varepsilon_0 \varepsilon_r kT}{q^2 N_D d}$$

9.2 金半接触的整流输运理论₃

9.2.1 扩散理论

积分



$$J \exp\left[-\frac{qV(x)}{kT}\right] = qD_n \frac{d}{dx} \left\{ n(x) \exp\left[-\frac{qV(x)}{kT}\right] \right\} \leftarrow \int_0^d dx$$

平衡态近似

$$\begin{aligned} n(0) &= n_0 \exp(qV_{s0}/kT) \\ &= n_0 \exp(-qV_D/kT) \end{aligned}$$

$$n(d) = n_0$$

$$qD_n \left\{ n(x) \exp\left[-\frac{qV(x)}{kT}\right] \right\} \Big|_0^d$$

$$V(x) = -\frac{qN_D}{2\epsilon_0\epsilon_r} (x^2 - 2xd) - \phi_{ns}$$

$$V(0) = -\phi_{ns}$$

$$V(d) = \frac{qN_D}{2\epsilon_r\epsilon_0} d^2 - \phi_{ns}$$

$$V(d) = -[\phi_{ns} - (V_D - V)]$$

$$= qD_n n_0 \exp\left[\frac{q}{kT} (\phi_{ns} - V_D + V)\right] - qD_n n_0 \exp\left(\frac{qV_{s0}}{kT}\right) \exp\left(\frac{q\phi_{ns}}{kT}\right)$$

$$-V_D = V_{s0}$$

$$= qD_n n_0 \exp\left[q(V_{s0} + \phi_{ns})/kT\right] \left[\exp(qV/kT) - 1\right]$$

9.2 金半接触的整流输运理论⁴

9.2.1 扩散理论

$$\int_0^d J \exp\left[-\frac{qV(x)}{kT}\right] dx = \int_0^d qD_n \frac{d}{dx} \left\{ n(x) \exp\left[-\frac{qV(x)}{kT}\right] \right\} dx$$

$$J \exp\left(\frac{q\phi_{ns}}{kT}\right) \frac{\epsilon_0 \epsilon_r kT}{q^2 N_D d} = qD_n n_0 \exp\left[\frac{q(V_{s0} + \phi_{ns})}{kT}\right] [\exp(qV/kT) - 1]$$

$$J = \frac{q^3 D_n n_0 N_D d}{\epsilon_0 \epsilon_r kT} \exp(-qV_D/kT) [\exp(qV/kT) - 1]$$

$$= \frac{q^2 D_n n_0}{kT} \left[\frac{2qN_D}{\epsilon_0 \epsilon_r} (V_D - V) \right]^{1/2} \exp(-qV_D/kT) [\exp(qV/kT) - 1]$$

$$= J_{SD} [\exp(qV/kT) - 1]$$

—适用于势垒宽度 \gg 电子平均自由程